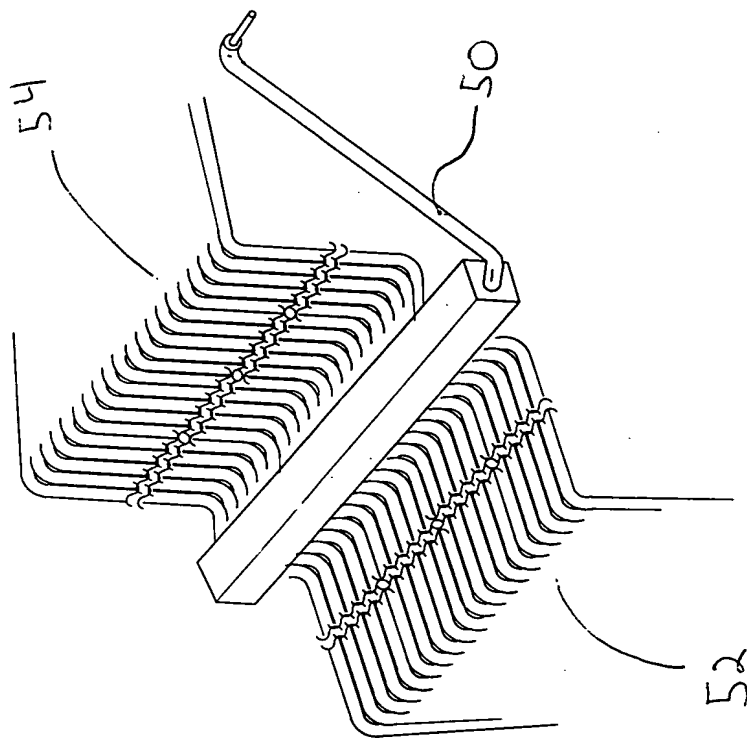


*Figure 1*

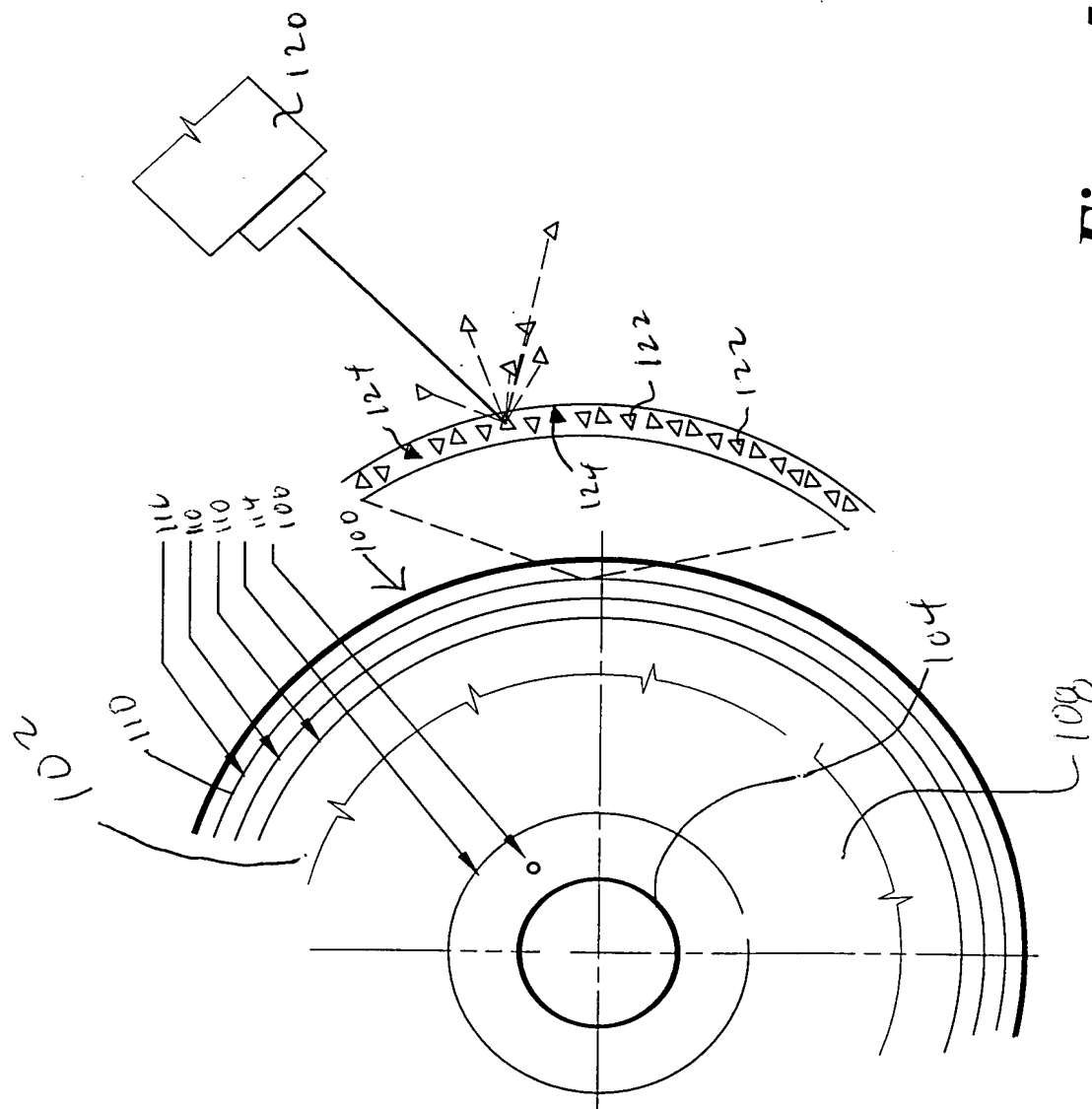


**Figure 2**



*Figure 3*





**Figure 5**

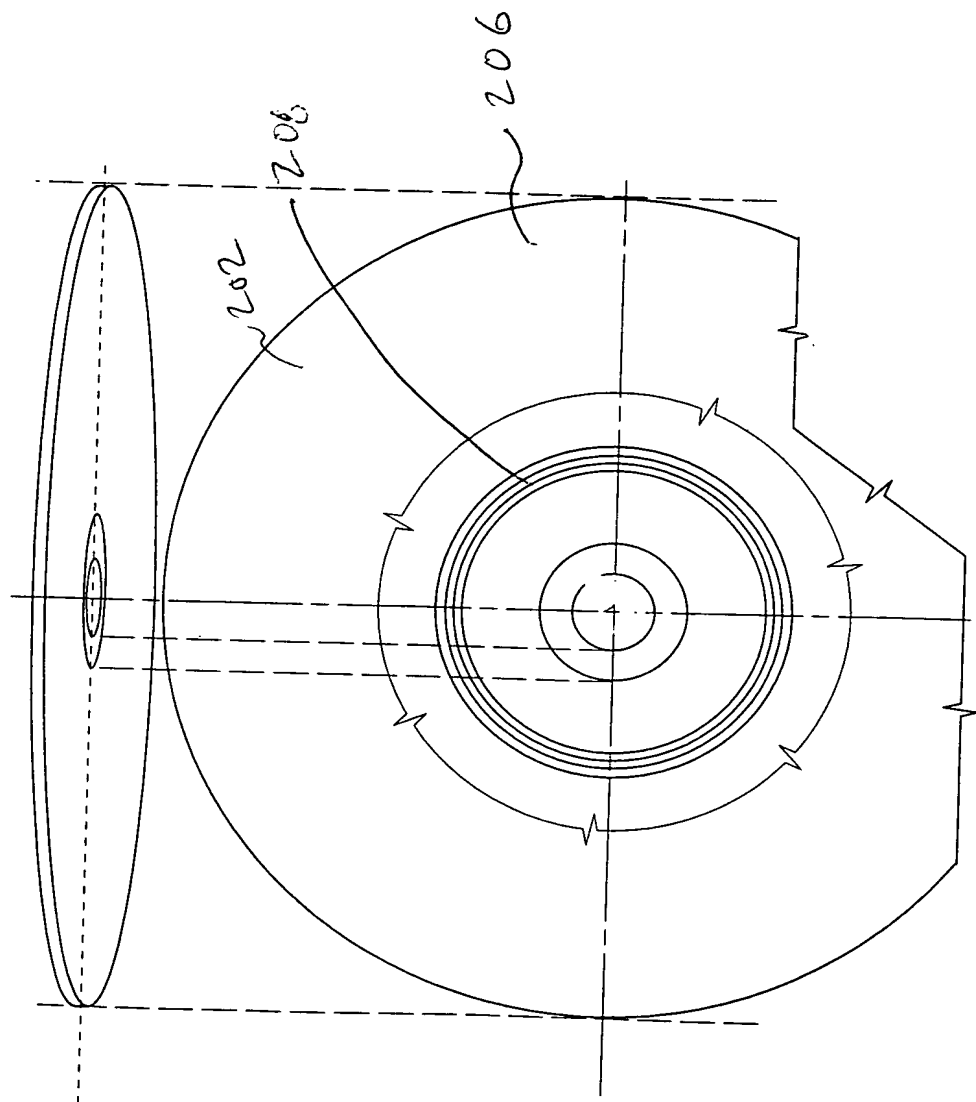
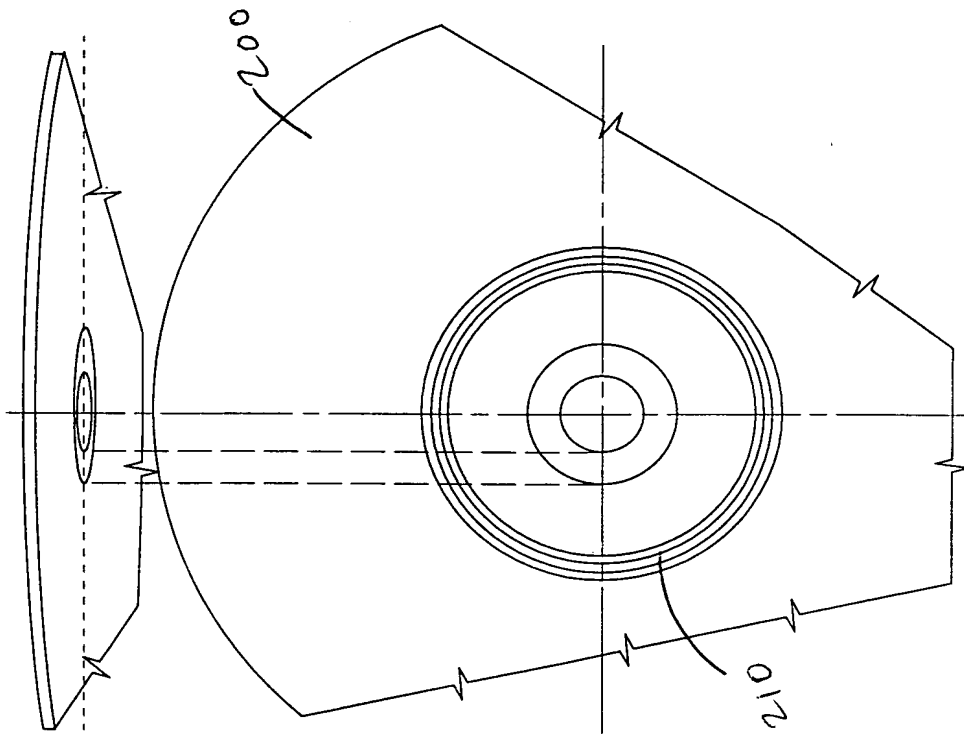
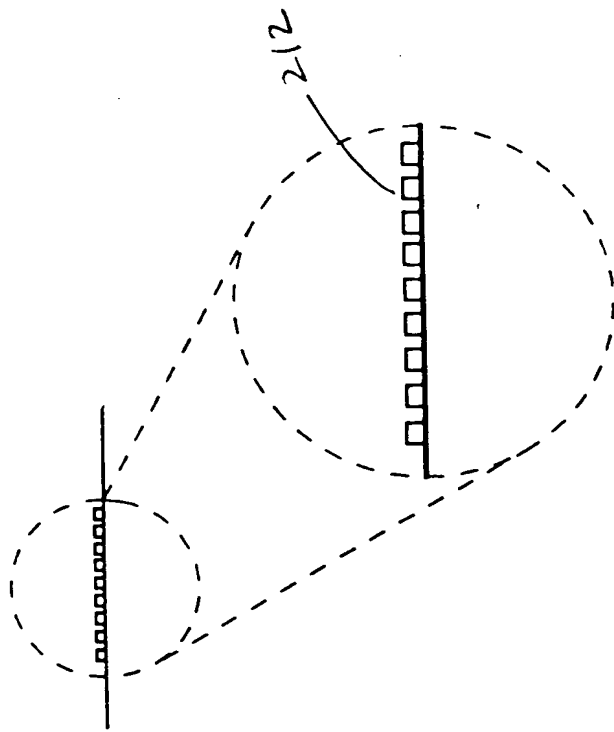


Figure 6

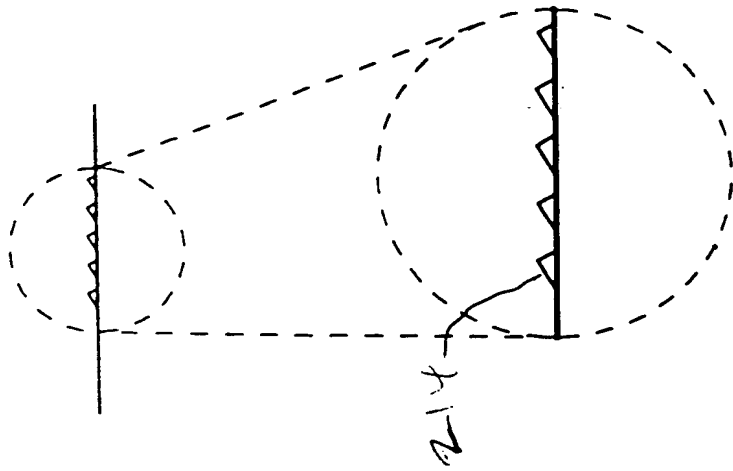
FIG. 7a is a schematic diagram of a device 100 in a cross-sectional view. The device 100 includes a substrate 110 and a layer 120 on the substrate 110. The layer 120 has a central region 121 and a peripheral region 122. The central region 121 is defined by a central axis 123. The peripheral region 122 is defined by a peripheral axis 124. The device 100 is shown in a cross-sectional view along the central axis 123 and the peripheral axis 124. The device 100 is shown in a cross-sectional view along the central axis 123 and the peripheral axis 124.



**Figure 7a**

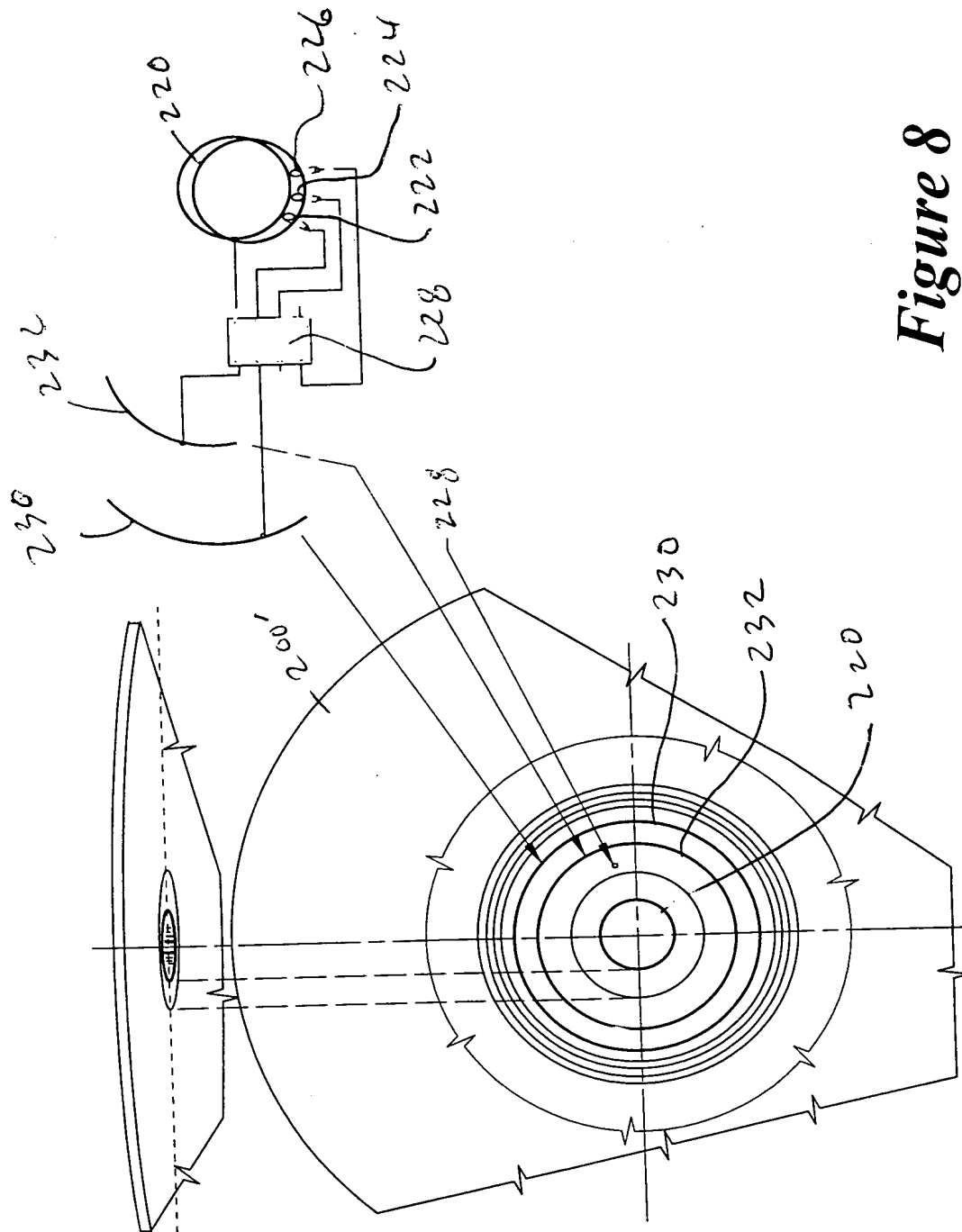


*Figure 7b*

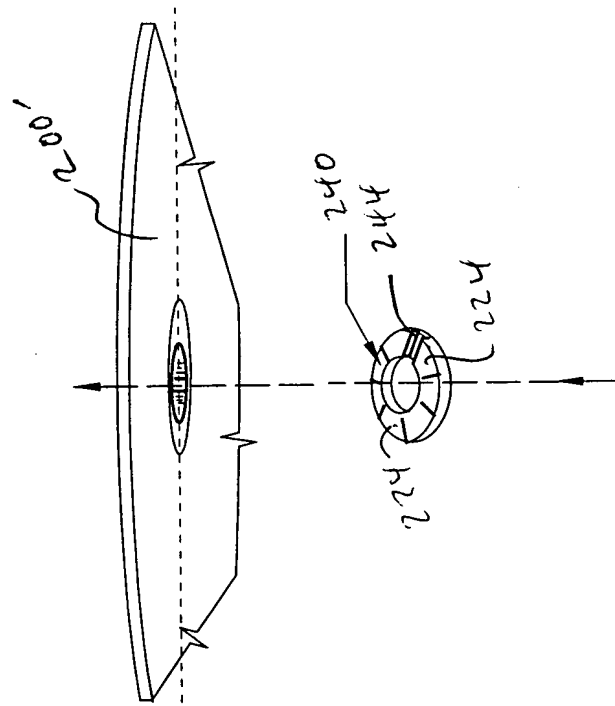


*Figure 7c*

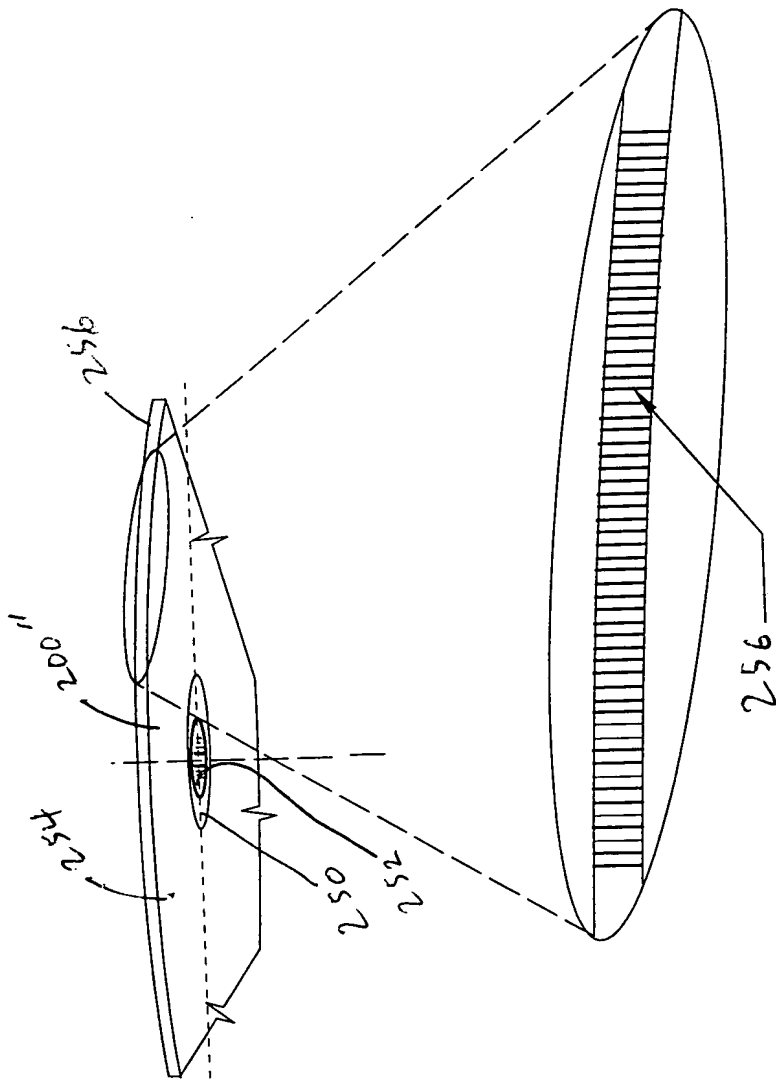




**Figure 8**



*Figure 9*



**Figure 10**

FIG. 11 is a block diagram of the system of FIG. 10, showing the connection of the film 31 to the system 8.

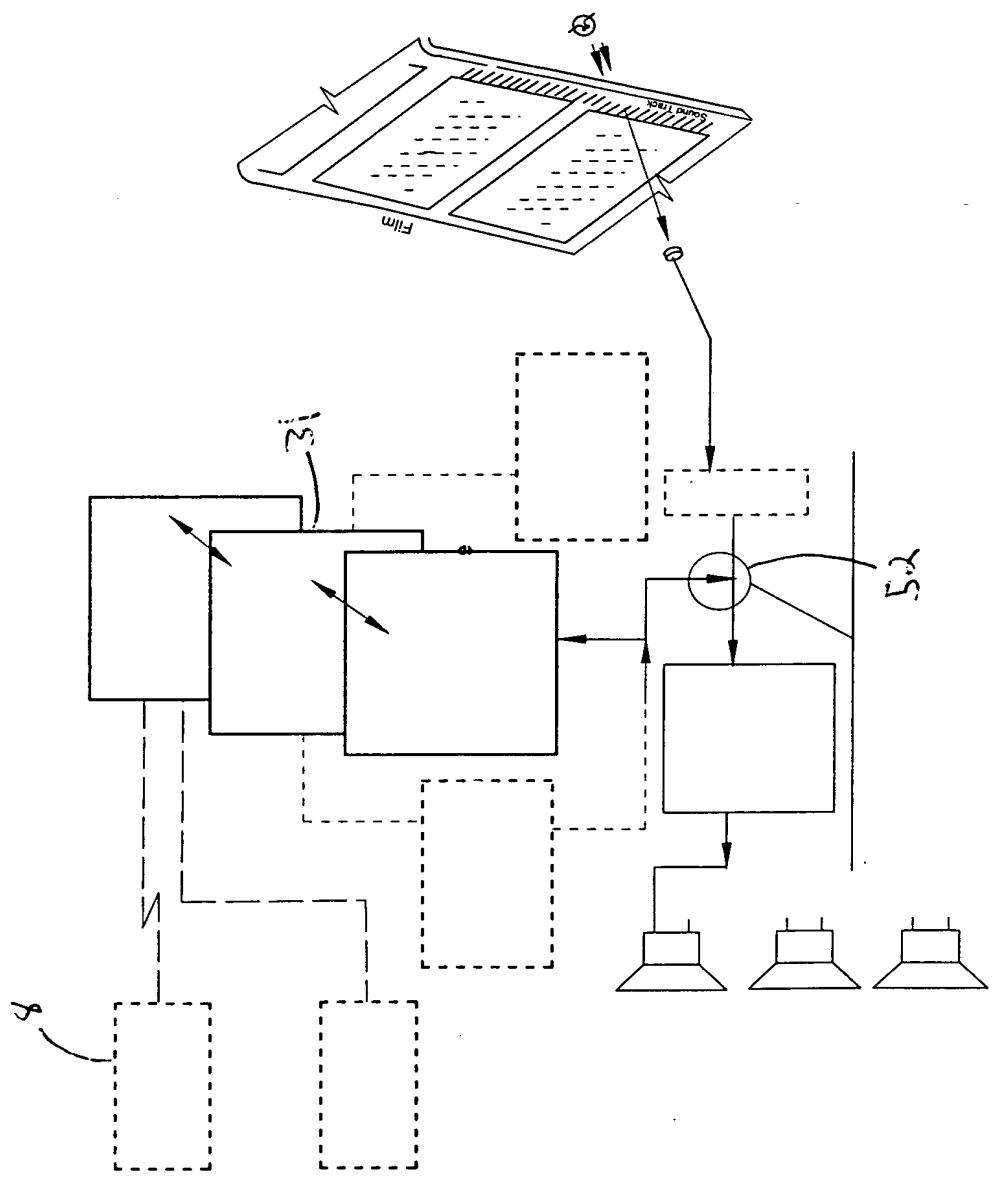
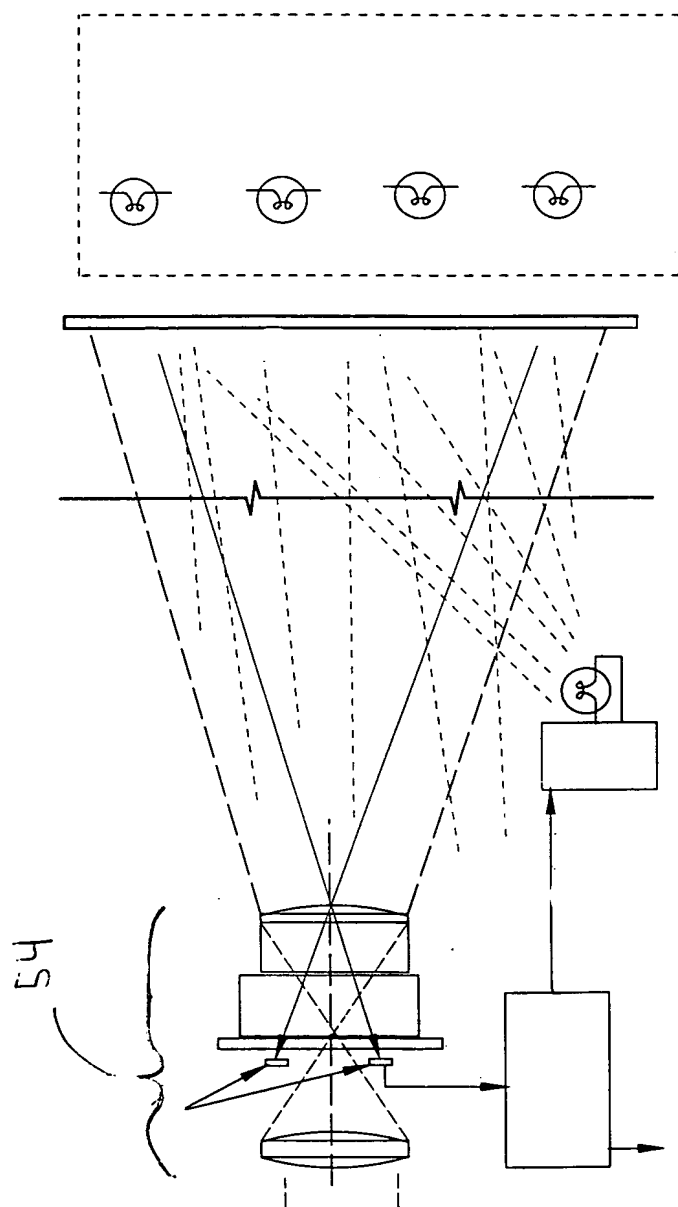


Figure 11



# Figure 12

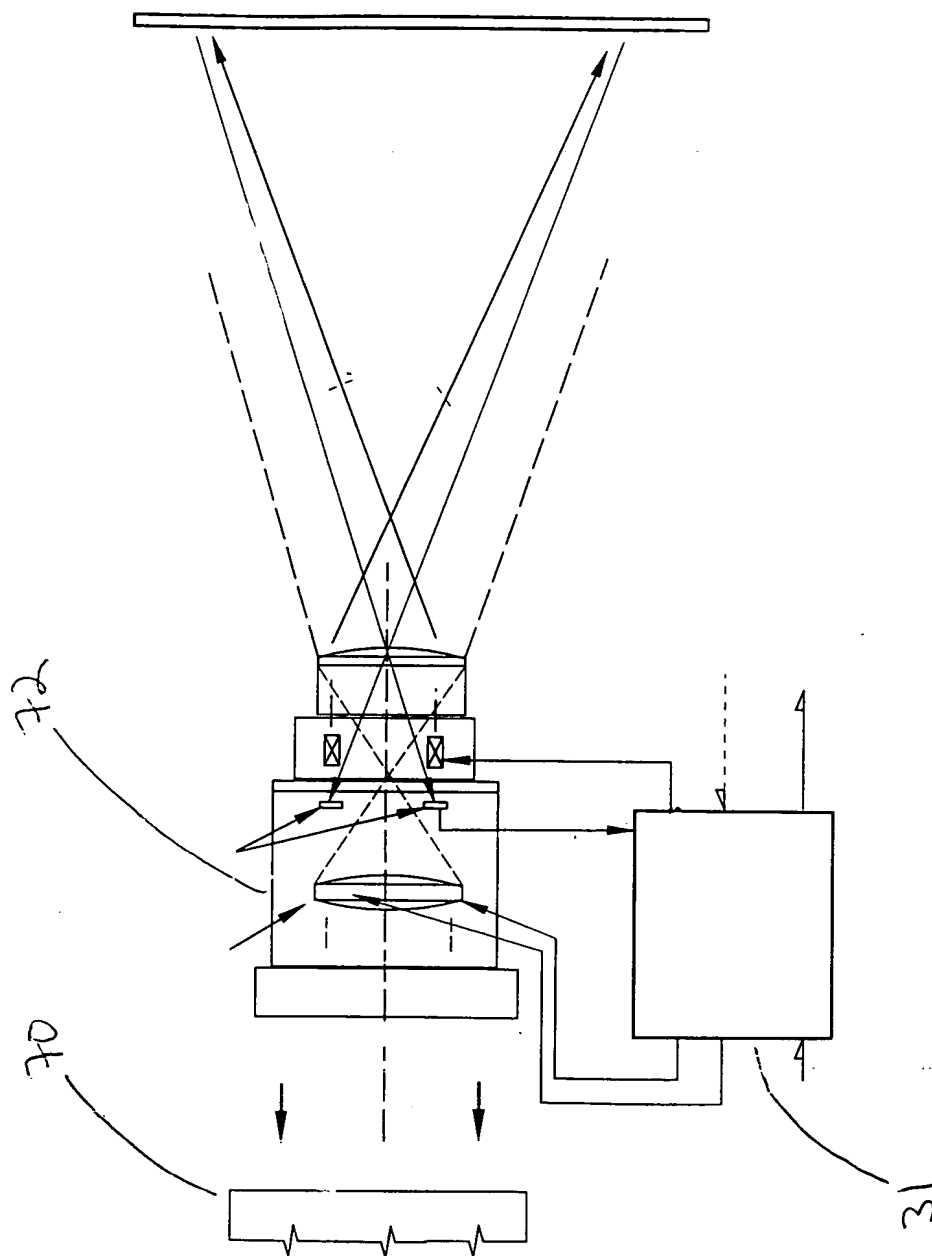


Figure 13